PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Jung Wook LIM, et al.

Serial No.: New Application Group Art Unit: Not Yet Assigned

Filed: August 22, 2003 Examiner: Not Yet Assigned

Title: METHOD OF FORMING A THIN FILM IN A SEMICONDUCTOR DEVICE

INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner for Patents PO Box 1450, Alexandria, VA 22313

August 22, 2003

Sir:

As a means of complying with the duty of disclosure under 37 CFR §1.56, and in accordance with 37 CFR §§1.97 and 1.98, Applicant(s), through the undersigned attorney, submits this Information Disclosure Statement. The patents, publications or other information submitted herewith are listed on the attached Form PTO-1449 and copies are attached.

In accordance with 37 CFR §1.97(b)(1) or (2), this Information Disclosure Statement is being filed either within three months of the filing date of the above-identified application, or within three months of the date of entry into the national stage of the above-identified application as set forth in 37 CFR §1.491. Accordingly, no fee is required.

Respectfully submitted,

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LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT

ATTY. DOCKET NO.: P69084US0				GROUP A	GROUP ART UNIT: Not Yet Assigned			
SERIAL	SERIAL NO.: Not Yet Assigned			FILING I	FILING DATE: August 22, 2003			
APPLICA	NT(S)	: Jung W	Jung Wook LIM, et al.		TODAY'S DATE: August 22, 2003			
*****	*****	*****	*****	*****	****	*****	*****	
			U.S. PA	ATENT DOCUMENTS				
*EXAMINER		DOCUMENT			INT'L	SUB-	FILING DATE	
INITIAL		NUMBER	DATE	NAME	<u>CLASS</u>	<u>CLASS</u>	(If Appropriate)	
	AA	6,416,822	7/09/02	Chiang, et al.	B05D	3/00	3/19/01	
	AB	6,468,924	10/22/02	<u>Lee, et al.</u>	H01L	21/31	5/31/01	
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			FOREIGN	PATENT DOCUMENTS				
		DOCUMENT				SUB-	TRANSLATION	
		<u>NUMBER</u>	DATE	COUNTRY	<u>CLASS</u>	<u>CLASS</u>	(YES) (NO)	
	AC	2002-46431	06/21/02	KOREA (ROK)	<u> H01L</u>	29/108	3 X	
	AD		-					
	AE							
*****	****	*****	*****	*****	*****	*****	*****	
	OTHER	ART (Includ	ling Author,	Title, Date, Per	rtinent Pa	ages, E	tc.)	
	AF Jin-Seong Park, et al.; "Plasma-Enhanced Atomic Layer Depositi							
		of Ta-N Thin Films"; Journal of The Electrochemical Society, 14 (1) C28-C32 (2002).						
	AG	Hyun-Jung Song, et al.; "Increment of the Dielectric Constant of Ta2O5 Thn Films by Retarding Interface Oxide Growth on Si Substrates"; Electtrochemica and Solid-State Letters, 4(7) F13-F14						
		(2001).	; Election	nemica and Solid-	<u>-state Let</u>	.cers, 4	<u>(/) F13-F14</u>	
EXAMINER		DATE CONSIDERED						

^{*} EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).